



AMENDMENT UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
GROUP 1752
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

KAWABE, YASUMASA, et al.

Appln. No.: 09/295,329

Group Art Unit: 1752

Confirmation No.: 7050

Examiner: Y. CLARKE

Filed: April 21, 1999

For: POSITIVE PHOTSENSITIVE RESIN COMPOSITION

AMENDMENT UNDER 37 C.F.R. §1.116

ATTN: BOX AF
Commissioner for Patents
Washington, D.C. 20231

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MAY 15 2002
TC 1700

Sir:

This Amendment is submitted in response to the Office Action dated January 10, 2002. A Petition for a one month extension of time is being concurrently filed, making a response due on or before May 10, 2002. Please amend the above-identified application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

Claim 23 (amended). The positive photosensitive resin composition as claimed in claim 1, wherein said polymer which has alicyclic hydrocarbon skeletons and decomposes under the action of an acid to become alkali soluble contains a